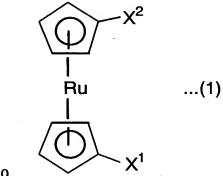
ABSTRACT

A ruthenium compound from which high-quality film-like metal ruthenium can be obtained and a process for producing a metal ruthenium film from the ruthenium compound by chemical vapor deposition.

The ruthenium compound as a material for chemical vapor deposition is represented by the following formula (1), for example.



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